Updated Spectrophotometric Investigation of Copper Complexes with Thiomicher's Ketone and **Bromopyrogallol Red**

HONG-WEN GAO*, YAN-QIN ZI†, JIA-SHAN GU and SU-MEI YE School of Chemistry and Chemical Engineering Anhui University, Hefei-230039, P.R. China

The novel investigation of the copper complexes with thiomicher's ketone (TMK) and bromopyrogallol red (BPR) was carried out at pH 7 by spectral correction technique. The characteristic factors were calculated, for example, complex ratio and stability constant. The results have shown that the Cu(TMK)₂ and Cu(BPR)₂ were formed and their real stepwise molar absorptivities were determined simply at pH 7. Their cumulative stability constants are 5.08×10^{11} and 5.02×10^{11} respectively.

Key words: spectral correction technique, copper complex, thiomicher's ketone, bromo-pyrogallol red.

INTRODUCTION

A number of colour reactions of copper are reported, e.g., with azo compounds^{1, 2}, hydrazone reagents^{3, 4}, nitroso-compounds⁵ etc.. Some of their highly sensitive reactions have been playing important roles in the spectrophotometric determination of trace amounts of copper^{6,7}. The two ligands, thiomicher's ketone (TMK) and bromo-pyrogaliol red (BPR) are also sensitive for chelating copper(II) . They have ever been used for the determination of trace silver^{8,9}, but the formation and the characteristic factors of their complexes have never been studied in detail. Here, two such complex reactions have been used to determine the characteristic factors of two complexes, which include complex ratio, stepwise real molar absorptivity, stepwise and cumulative stability constant. The spectral correction technique 10, 11 was applied to the determination of the above factors. This method is simpler and more acceptable than the other classical ways, e.g., molar ratios¹², continuous variations¹³, equilibrium movement¹⁴ and Yatzimirsky factor¹⁵ because it can eliminate the interference of the excess of TMK or BPR and give the accurate absorbance of the Cu complexes. On the contrary, the traditional methods are often limited because of the excess of ligand in its complex solution.

Principle

The following expression¹⁰ is developed for the determination of the real absorbance (A_c) of metal (M) complex (ML_γ) with a ligand (L). $A_c = \frac{\Delta A - \beta \Delta A'}{1 - \alpha \beta}$

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The terms, ΔA and $\Delta A'$ are the absorbances of the mixed solution of ML_{γ} and

[†]Department of Chemistry, Huaibei Coal Normal College, Huaibei-235000, P.R. Chin

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excess L measured at wavelengths λ_2 and λ_1 against the reagent blank, respectively. The coefficients, α and β are correction factors and they are able to be measured from only ML_Y solution and L solution is then computed as follows.

$$\alpha = \frac{\varepsilon_{ML_{\gamma}}^{\lambda_{1}}}{\varepsilon_{ML_{\gamma}}^{\lambda_{2}}} \quad \text{and} \quad \beta = \frac{\varepsilon_{L}^{\lambda_{2}}}{\varepsilon_{L}^{\lambda_{1}}}$$

The terms $\epsilon_{ML_{\gamma}}^{\lambda_1}$, $\epsilon_{ML_{\gamma}}^{\lambda_2}$, $\epsilon_L^{\lambda_1}$ and $\epsilon_L^{\lambda_2}$ are the molar absorptivities of ML_{γ} and L at wavelengths λ_1 and λ_2 , respectively. The molar ratio $\lambda_2(\gamma')$ of the effective L to M is calculated by the relation:

$$\gamma' = \eta \times \frac{C_L}{C_M}$$
 and $\eta = \frac{A_c - \Delta A}{A_0}$

The term η indicates the reacted percentage of L and both C_M and C_L are the molar concentrations of M and L at the beginning. A_0 is the absorbance of the L solution measured at wavelength λ_2 . If γ' reaches maximum and remains constant, it was thought that $\gamma = \gamma'$ where γ is a natural number and it is named the stoichiometric ratio of the complex. In addition, the following expression was established for the stepwise stability constant (K_n) of complex ML_{γ}

$$K_n = \frac{\gamma' + (1 - n)}{(n - \gamma')(C_L - \gamma'C_M)}$$

From each K_n the cumulative constant (K) of complex ML_γ is able to be calculated from the following expression:

$$K = K_1 \times K_2 \times \ldots \times K_n \times \ldots \times K_{\gamma}$$

In addition, from such an M-L reaction the stepwise absorptivity (real $\varepsilon_{\text{ML}_n}^{\lambda_2}$ not apparent $\varepsilon_n^{\lambda_2}$, $n = 1, 2, \ldots, \gamma$) of complex ML_{γ} may be expressed as follows:

$$\epsilon_{ML_n}^{\lambda_2} = \frac{A_c}{\delta C_M(\gamma + 1 - n)} - \frac{n - \gamma'}{(\gamma' + 1 - n)} \, \epsilon_{ML_{n-1}}^{\lambda_2}$$

where δ is the cell thickness (cm) and the other symbols have the same meanings as the above.

EXPERIMENTAL

Absorbances were measured on a TU1901 spectrophotometer (P General, Beijing) with 1.0-cm cells.

TMK solution (0.50 mmol/L) was prepared by dissolving 0.1421 g of TMK (Shanghai Third Reagent) in 1000 mL of acetone and BPR solution (1.00 mmol/L) was prepared by dissolving 0.582 g of BPR (Shanghai Third Reagent) in 1000 mL of deionized water. Cu(II) standard solution, 100.0 mg/L, was prepared with copper sulfate (AR, Shanghai Reagent) and 10.0 mg/L Cu use solution was prepared daily by diluting the solution. The buffer solution pH 5 was prepared with acetic acid and sodium acetate and the anionic surfactant 5% SDBS was used in the Cu-BPR solution.

Recommended Procedure

 $20~\mu g$ copper was taken in a 25-mL calibrated flask. Added 2~mL of the buffer solution, TMK or BPR solution and in addition 1~mL of 5% SDBS in the Cu-TMK solution. Diluted to the mark with deionized water and well-mixed. Between 20~and~30~min, measured the absorbances of the Cu-TMK solution at 440~and~620~nm and those of the Cu-BPR solution at 560~and~620~nm, respectively. A_c of the complexes has been calculated by the above equation.

RESULTS AND DISCUSSION

Absorption spectra: The reaction between copper and BPR is sensitive in the absence of surfactant but the reaction between copper and TMK gave a high sensitivity only in the presence of anionic surfactant, e.g., SDBS. Their absorption spectra are shown in Fig. 1. We find that the peak and valley absorptions of the Cu-BPR solution are located at wavelengths $\lambda_1 = 440$ and $\lambda_2 = 620$ nm from curve

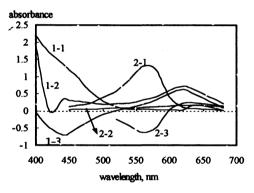


Fig. 1. Absorption spectra of reagent blank and copper complex solutions: I-1, TMK solution in presence of SDBS at pH 7 against water; 1-2, only Cu-TMK complex solution in presence of SDBS at pH 7 against water; 1-3, Cu-TMK reaction solution in presence of SDBS at pH 7 against reagent blank; 1-1, BPR solution at pH 7 against water; 1-2, only Cu-BPR complex solution at pH 7 against water; 1-3, Cu-BPR reaction solution at pH 7 against reagent blank.

1-3 and those of the Cu-TMK solution at $\lambda_1=560$ and $\lambda_2=620$ nm from curve 2-3. From curves x-1 and x-2, β and α are calculated. So the following equations were used: $A_c=1.01(\Delta A-0.022\Delta A')$ for calculation of the real absorbance of the Cu-TMK complex and $A_c=1.06(\Delta A-0.086\Delta A')$ for that of the Cu-BPR complex.

Effect of TMK and BPR concentration: By varying the addition of the TMK and BPR solutions, the absorbances of their Cu (0.80 mg/L) complexes are shown in Fig. 2. Both the positive and negative absorptions approach maximum from curves 1-1 and 2-1, when the concentration of TMK and BPR is more than 0.040 mmol/L. We have calculated the real absorbance (A_c) and complex ratio (γ) and the results are shown in Fig. 3. From curves x-2, we observed that γ approaches 2. Therefore, the formed complexes are expressed as Cu(TMK)₂ and Cu(BPR)₂ at pH7.

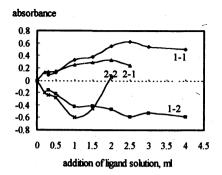


Fig. 2. Effect of ligand concentration on the measured absorbances: 1-1, reagent blank (TMK) in the presence of SDBS at pH 7 against water at 440 nm; 1-2, Cu(0.8 mg/L)-TMK-SDBS system at pH 7 against reagent blank at 620 nm; 1-3, same as 1-2 but at 440 nm; 2-1, reagent blank (BPR) at pH 7 against water at 560 nm; 1-2, Cu (0.8 mg/L)-BPR system at pH 7 against reagent blank at 620 nm; 1-3, same as 1-2 but at 560 nm.

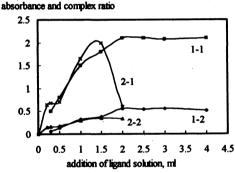


Fig. 3. Effect of ligand concentration on real absorbance A_c and the complex ratio, γ': 1-1, A_c of Cu-TMK complex in the presence of SDBS at pH 7 at 620 nm; 1-2, γ' of Cu-TMK-SDBS reaction system; 2-1, A_c of Cu-BPR complex at pH 7 at 620 nm; 2-2, γ' of Cu-BPR reaction system

Effect of pH and time: By varying pH of the solutions containing 20 µg of copper, the absorbance change is shown in Fig. 4. Both the reactions approach maximum at pH 7. So pH 7 was selected in this study. The absorbances of the Cu (0.80 mg/L) complexes with TMK and BPR were measured at various reaction times and the effect is shown in Fig. 5. We see that the absolute absorbances reach maximum between 20 and 30 min. The absorbances begin to fall down when the reaction is over 30 min.

Determination of stepwise absorptivity and stability constant of the complexes: The following solutions was prepared and measured for the determination of the stepwise absorptivity and stability constants of complexes: 0.10 μmol of Cu(II) plus 0.20 μmol of TMK, 0.10 μmol of Cu(II) plus 0.30 μmol of TMK, 0.10 μmol of Cu(II) plus 0.30 μmol of Cu(II) plus 0.30 μmol of BPR. The measurement results are shown in Table 1. The stepwise absorptivities and stability constants of the complexes all were calculated and presented in Table 1.

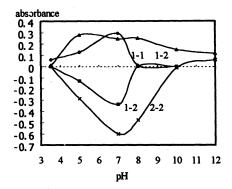


Fig. 4. Effect of pH on measurement of copper complex solution containing 20 μg Cu(II): 1-1, Cu-TMK-SDBS system containing 0.50 μmol TMK at 620 nm against reagent blank; 1-2, same as 1-1 but at 440 nm; 2-1, Cu-BPR system containing 1.00 μmol BPR at 620 nm against reagent blank; 2-2, same as 2-1 but at 560 nm

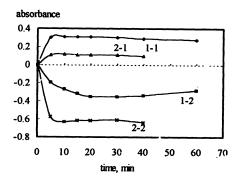


Fig. 5. Effect of colour-developed time on measurement of copper complex solution containing 20 μg Cu(II): 1-1, Cu-TMK-SDBS system containing 0.50 μmol TMK at 620 nm against reagent blank; 1-2, same as 1-1 but at 440 nm; 2-1, Cu-BPR system containing 1.00 μmol BPR at 620 nm against reagent blank; 2-2, same as 2-1 but at 560 nm;

TABLE-1

DETERMINATION OF STEPWISE ABSORPTIVITY AND STABILITY CONSTANT OF COPPER COMPLEX AT pH 7, ION STRENGTH 0.01 AND TEMPERATURE 25°C

M-L solution	Average A _c of three determinations at 620 nm	Average γ'	Average K ₂ × 10 ⁶	Average ε _r	L mol ⁻¹ cm ⁻¹
Cu (0.004 mmol/L)- TMK (0.008 mmol/L)	0.043	0.910	K ₁ 2.330	1st step ML	1.18×10^4
Cu (0.004 mmol/L)- TMK (0.012 mmol/L)	0.063	1.550	K ₂ 0.218	2nd step ML ₂	1.89×10^4
Cu (0.004 mmol/L)- BPR (0.008 mmol/L)	0.057	0.902	K ₁ 2.180	1st step ML	1.58×10^4
Cu (0.004 mmol/L)- TBPR (0.012 mmol/L)	0.076	1.550	K ₂ 0.230	2nd step ML ₂	2.16×10^4

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REFERENCES

- 1. A.L. El-Ansary and M.M. Omar, Egypt. J. Chem., 29, 511 (1986).
- 2. G.M. Castillo, R.J. Thibert, and N.D. Seudeal, Microchem. J., 37, 99 (1988).
- 3. Elzbleta Welteska and Zenon Szczepaniak, Chem. Anal., 32, 481 (1987).
- 4. Tasutoshi Kanetak and Makoto Otcmo, Anal. Sci., 4, 411 (1988).
- 5. R.M. Issa, F.A. Aly, M.A. El-Ries and F.M. Abu-Atia, Egypt. J. Pharm. Sci., 28, 99 (1987).
- A. Bermejo Barrera, M.M. Guisasola Escudero and F. Bermejo Martinez, Quim. Anal., 7, 212 (1988).
- 7. Y.N. Ni, Fenxi Huaxue, 15, 995 (1987).
- 8. M.T. El-Ghamry, Anal Chem., 40, 1936 (1968).
- 9. G F. Zhang, Liliua Jianyan-Huaxue Fence, 25, 312 (1989).
- 10. H.W. Gao, Talanta, 42, 891 (1995).
- 11. ———, Indian J. Chem., 35A, 41 (1996).
- 12. L.C. Kamra, Anal. Chim. Acta, 78, 423 (1975).
- 13. W. Likussar, Anal. Chem., 45, 1926 (1973).
- 14. A.I. Laearev, Zavod. Lab., 41, 534 (1975).
- 15. K.B. Yatzimirsky, Zhur Neorg Khim, 1, 2306 (1956).

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